

Phase equilibria in ternary RE–Si–N systems (RE=Sc, Ce, Ho)

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Phase equilibria in the ternary systems Sc–Si–N, Ce–Si–N and Ho–Si–N at 1000 °C and the binary boundary system Ho–Si are investigated. No new binary or ternary phases are found. In all three systems the respective rare-earth mononitride dominates the ternary phase fields and, with the exception of HoSi₂ in the Ho–Si–N system, coexists with all binary silicides. Thus Si₃N₄ is decomposed in contact with either scandium, cerium or holmium with the formation of ScN + ScSi_{2–x}, CeN + CeSi₂ and HoN + HoSi_{2–x}, respectively.

1. Introduction

Besides the existence of the two ternary phases LaSi₃N₅ [1, 2] and Sm₃Si₆N₁₁ [3] no data exist in the literature on ternary rare-earth metal–silicon–nitrogen systems. However, the binary systems RE–Si are established sufficiently to distinguish three groups of systems, each characterized by the occurrence and crystal structures of the intermediate phases (Fig. 1, Table I). Thus within a series of investigations of metal–silicon–nitrogen systems [4–7], one rare-earth metal of each group is chosen and the phase equilibria of the corresponding ternary systems are investigated as representative for the respective group: Ce–Si–N for group I (La, Ce, Pr and Nd); Ho–Si–N for group II (Sm, Gd, Tb, Dy, Ho, Er and Y); Sc–Si–N for group III (Tm, Yb, Lu and Sc).

2. Experimental procedure

Binary and ternary alloys were prepared from powders using Si (powder, purity 99.9%, Alpha Division, Ventron Corp., USA), Sc (pieces, purity 99.99%, Rare-Earth Products Ltd, UK), Ce (ingot, purity 99.9%, Rare-Earth Products Ltd.), Ho (powder, purity 99.9%, Alpha Division) and Si₃N₄ powder (mixture of α-Si₃N₄ and β-Si₃N₄, Si content 53%, Alpha Division). Appropriate mixtures of rare-earth metal and silicon were cold compacted and arc melted to prepare master alloys which were powdered (in the case of Ce alloys under a controlled atmosphere) and mixed with Si₃N₄ powder. Compacts of these mixtures were wrapped in Mo foil, sealed in evacuated quartz tubes and sintered at 1000 °C up to 1000 h. These alloys were water quenched and examined by X-ray diffraction (CuKα₁ radiation) using Guinier–Huber as well as 116 mm radius Debye–Scherrer cameras.

3. Results and discussion

3.1. Scandium–silicon–nitrogen system

The three binary intermediate phases ScSi_{2–x} [8] (or Sc₃Si₅), ScSi [9] and Sc₅Si₃ [10] are corroborated to exist at 1000 °C. The crystal structures and lattice parameters found are in excellent agreement with the values reported. However, the phase ScSi_{2–x} is not observed after prolonged annealing at 800 °C. At this temperature ScSi coexists with Si, at variance with the proposed phase diagram [11].

No ternary phase is found in the Sc–Si–N system. At 1000 °C, Si₃N₄ reacts with up to 45 at % Sc to form ScSi_{2–x} and ScN (Table II), the only intermediate phase reported for the binary system Sc–N [12]. ScN coexists furthermore with ScSi and Sc₅Si₃ (Fig. 1). Owing to the decomposition of ScSi_{2–x} at temper-

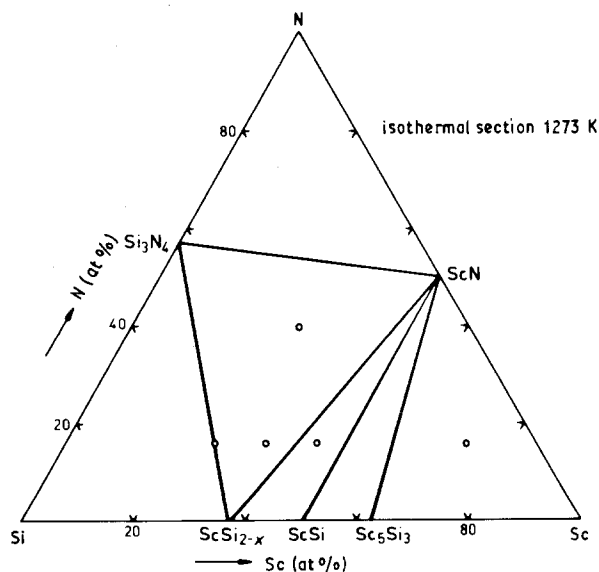


Figure 1 Isothermal section of the Sc–Si–N system at 1000 °C.

TABLE I Classification of the binary systems RE–Si according to occurrence and crystal structure of the intermediate phases (the systems Eu–Si and Pm–Si are not included, because the data available are not sufficient for classification)

Group	Element	RESi ₂	RESi _{2-x} (RE ₅ Si ₃)	RESi	RE ₅ Si ₄	RE ₅ Si ₃
I	La Ce Pr Nd				Zr ₅ Si ₄ -type	Cr ₅ B ₃ -type
II	Sm Gd Tb Dy Ho Er Y	GdSi ₂ -type ThSi ₂ -type	defect-ALB ₂ -type	FeB-type CrB-type	Sm ₅ Ge ₄ -type	Mn ₅ Si ₃ -type
III	Tm Yb Lu Sc					

TABLE II Solid state reaction products observed in the system Sc–Si–N upon annealing at 1000 °C for 170 h (in evacuated quartz tubes)

Si ₃ N ₄ + 30 at % Sc	→	Si ₃ N ₄ + ScN	(water quenched)
	→	Si ₃ N ₄ + ScN + Si	(slow cooling)
Si ₃ N ₄ + 72 at % Sc	→	Sc ₅ Si ₃ + ScN	(water quenched)
Sc _{0.375} Si _{0.625} + Si ₃ N ₄ (16 at % N)	→	ScSi _{2-x} + Si ₃ N ₄	(water quenched)
	→	ScN + ScSi + Si	(slow cooling)
Sc _{0.50} Si _{0.50} + Si ₃ N ₄ (16 at % N)	→	ScSi _{2-x} + Si ₃ N ₄ + ScN	(quenched)
	→	ScN + ScSi + Si	(slow cooling)
Sc _{0.675} Si _{0.325} + Si ₃ N ₄ (16 at % N)	→	ScSi + ScN	(+ unreacted Si ₃ N ₄)

atures below 1000 °C > T > 800 °C, additional phases are repeatedly observed in air-quenched specimens, which indicates that ScN dominates completely the phase equilibria below 1000 °C > T > 800 °C, e.g. at 800 °C (Fig. 2).

3.2. Cerium–silicon–nitrogen system

The binary phase diagram Ce–Si, originally due to Benesovsky *et al.* [13], and updated by Gschneidner and Verkade [14], was reassessed by Munitz *et al.* [15]. The six intermediate phases reported to exist at 1000 °C are corroborated in the present investigation: CeSi₂ (I4₁amd, ThSi₂-type, *a* = 0.4189 nm, *c* = 1.3892 nm); CeSi_{2-x} (Im \bar{m} a, GdSi₂-type, *a* = 0.4195 nm, *b* = 0.4123 nm, *c* = 1.3905 nm); CeSi (Pnma, FeB-type, *a* = 0.8302 nm, *b* = 0.3965 nm, *c* = 0.5967 nm); Ce₅Si₄ (P4₁2₁2 or P4₃2₁2, Zr₅Si₄-type, *a* = 0.7949 nm, *c* = 1.5069 nm); Ce₃Si₂ (P4/mbm, U₃Si₂-type, *a* = 0.7800 nm, *c* = 0.4365 nm) and Ce₅Si₃ (I4/mcm, Cr₅B₃-type, *a* = 0.7896 nm, *c* = 1.3722 nm).

No ternary phase is observed at 1000 °C in the Ce–Si–N system in the absence of external nitrogen pressure (Table III). Si₃N₄ reacts with up to 40 at % Ce to form CeSi₂ and CeN the only binary cerium nitride [16]. CeN coexists with all six binary cerium silicides (Fig. 3). The lattice parameters of the binary phases do not change upon equilibration with the

respective third component indicating negligible solubility for it.

3.3. Holmium–silicon–nitrogen system

Because no proposal exists for the constitution of the binary boundary system holmium–silicon, a tentative phase diagram is compiled (Fig. 4) from X-ray (Table

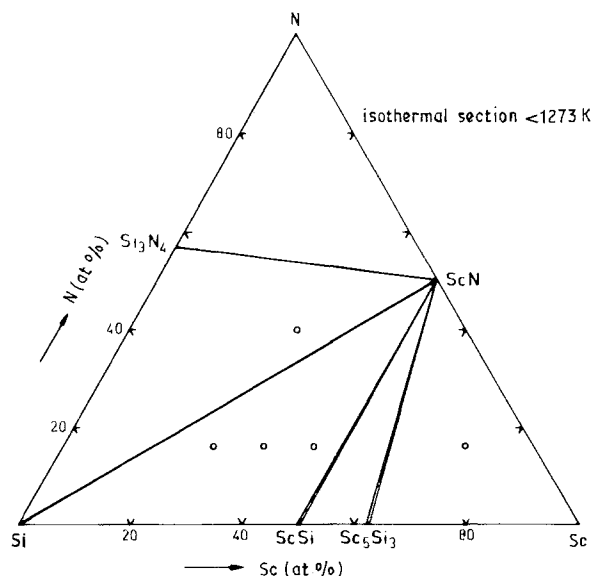


Figure 2 Isothermal section of the Sc–Si–N system at 800 °C.

TABLE III Solid state reaction products observed in the system Ce-Si-N upon annealing at 1000 °C for 240 h (in evacuated quartz tubes)

Si ₃ N ₄ + 25 at % Ce	→	CeN + CeSi ₂ + Si ₃ N ₄
Si ₃ N ₄ + 52 at % Ce	→	CeN + Ce ₅ Si ₄
Ce _{0.825} Si _{0.175} + Si ₃ N ₄ (16 at % N)	→	CeN + Ce ₅ Si ₃ + Ce
Ce _{0.60} Si _{0.40} + Si ₃ N ₄ (8 at % N)	→	CeN + Ce ₅ Si ₄ + CeSi
Ce _{0.60} Si _{0.40} + Si ₃ N ₄ (20 at % N)	→	CeN + CeSi ₂ + CeSi _{2-x} + Si ₃ N ₄ (no equilibrium)
Ce _{0.50} Si _{0.50} + Si ₃ N ₄ (11 at % N)	→	CeN + CeSi _{2-x}
Ce _{0.50} Si _{0.50} + Si ₃ N ₄ (20 at % N)	→	CeN + CeSi ₂ + CeSi _{2-x} + Si ₃ N ₄ (no equilibrium)
Ce _{0.33} Si _{0.67} + Si ₃ N ₄ (20 at % N)	→	Si ₃ N ₄ + CeSi ₂

TABLE IV Results of X-ray analysis of binary Ho-Si alloys

Ho (at %)	As-cast	Annealed 1600 °C, 5 h	Annealed 1000 °C, 660 h
15	Si + HoSi ₂		
20	Si + HoSi ₂		
25	Si + HoSi ₂		Si + HoSi ₂
33	HoSi ₂ + HoSi _{2-x}		HoSi ₂ + HoSi _{2-x}
35	HoSi ₂ + HoSi _{2-x}		HoSi ₂ + HoSi _{2-x}
37.5	HoSi _{2-x}		HoSi _{2-x}
39	HoSi _{2-x} + HoSi (FeB)		
43		HoSi _{2-x} + HoSi (FeB)	HoSi _{2-x} + HoSi (FeB)
47.5	HoSi _{2-x} + HoSi (FeB) + HoSi (CrB)		
50	HoSi _{2-x} + HoSi (FeB) + HoSi (CrB)	HoSi (FeB)	HoSi (FeB) + HoSi (CrB)
52	HoSi (FeB) + HoSi (CrB)		
55	HoSi (CrB) + Ho ₅ Si ₄ + trace Ho ₅ Si ₃	HoSi (CrB) + Ho ₅ Si ₄ + trace Ho ₅ Si ₃	
57.5	HoSi (CrB) + Ho ₅ Si ₄ + Ho ₅ Si ₃		HoSi (CrB) + Ho ₅ Si ₃
58	Ho ₅ Si ₄ + Ho ₅ Si ₃		
62.5	trace Ho ₅ Si ₄ + Ho ₅ Si ₃	Ho ₅ Si ₃	
70	Ho ₅ Si ₃ + Ho		
80	Ho ₅ Si ₃ + Ho		
90	Ho ₅ Si ₃ + Ho		

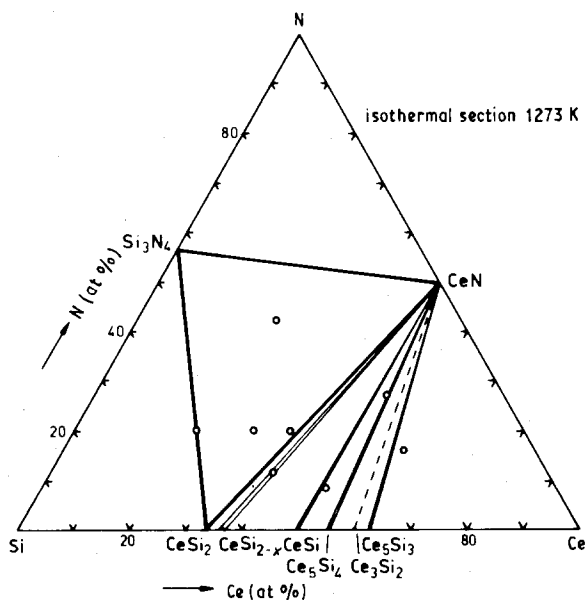


Figure 3 Isothermal section of the Ce-Si-N system at 1000 °C.

IV), metallographic and melting point data. All six intermediate phases reported in the literature are corroborated with respect to crystal structures and lattice parameters (Table V). The eutectic reaction, Si + HoSi₂ ⇌ liquid, occurs near 20 at % Ho at 1270 °C. This value is only in fair agreement with the value of 1185 °C and 27 at % Ho given by Losovskii and Kozelnichenko [23]. HoSi₂ melts incongruently

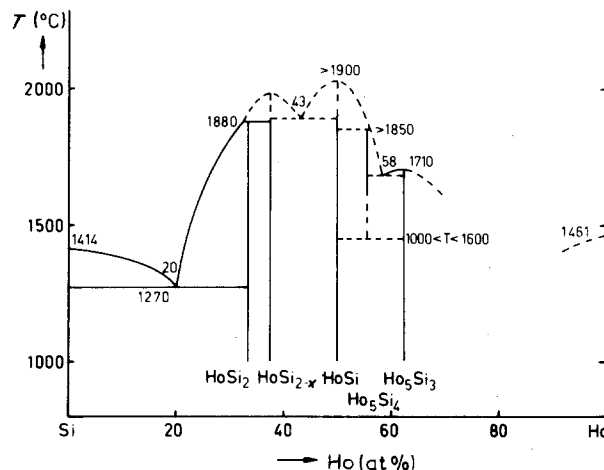


Figure 4 Tentative phase diagram of the binary Ho-Si system.

around 1880 °C. HoSi_{2-x} and HoSi both melt congruently at T > 1900 °C. The eutectic, HoSi_{2-x} + HoSi ⇌ liquid, occurs near 43 at % Ho. The FeB-type structure modification of HoSi was found in HoSi containing alloys consisting of less than 50 at % Ho; the CrB-type modification dominates Ho-rich HoSi alloys (Table IV). Thus a composition-dependent phase transition is more likely than a temperature-dependent transformation h-HoSi → r-HoSi. The phase Ho₅Si₄ is assumed to melt incongruently at T > 1850 °C and is found to decompose below 1600 °C > T > 1000 °C into HoSi (CrB-type) and

TABLE V Structural data of the intermediate phases in the system Ho-Si

Ho (at %)	Phase	Lattice parameters (nm)			Reference
		a	b		
33	HoSi ₂ (Imma, GdSi ₂ -type)	0.402 8(1)	0.391 2(1)	1.328 7(5) (coex. with Si)	Present work
		0.401 0(7)	0.391 2(6)	1.325 5(17) (coex. with HoSi _{2-x})	Present work
		0.403	0.392	1.329	[17]
		0.403	0.397	1.331	[17]
		0.399	0.394	1.330	[20]
> 33	HoSi _{2-x} (P6/mmm, AlB ₂ -type)	0.381 48(6)		0.410 73(5) (coex. with HoSi ₂)	Present work
		0.380 42(6)		0.410 75(5) (coex. with HoSi (FeB))	Present work
		0.381 6(3)		0.410 7(3)	[17]
50	HoSi (Pnma, FeB-type)	0.780 39(4)	0.379 95(4)	0.562 82(7) (coex. with HoSi _{2-x})	Present work
		0.780 9(4)	0.380 6(1)	0.563 7(2) (coex. with HoSi (CrB))	Present work
		0.780 8	0.380 1	0.563 3	[17, 18]
		0.781	0.379	0.563	[17]
50	HoSi (Cmcm, CrB-type)	0.423 2(1)	1.043 2(3)	0.380 4(1) (coex. with HoSi (FeB))	Present work
		0.422 9(1)	1.045 0(1)	0.380 8(2) (coex. with Ho ₅ Si ₄)	Present work
		0.422 8	1.042 9	0.380 1	[17, 18]
55	Ho ₅ Si ₄ (Pnma, Sm ₅ Ge ₄ -type)	0.731 8(9)	1.444 2(15)	0.763 1(1)	Present work
		0.733 8(5)	1.444 9(5)	0.762 5(5)	[19]
62	Ho ₅ Si ₃ (P6 ₃ /mcm, Mn ₅ Si ₃ -type)	0.833 6(2)		0.623 8(5) (coex. with HoSi (CrB))	Present work
63		0.835 6(1)		0.627 3(4) (coex. with Ho)	Present work
		0.834		0.622	[17]
		0.834 1(3)		0.625 3	[21]
		0.830 3		0.622 4	[22]

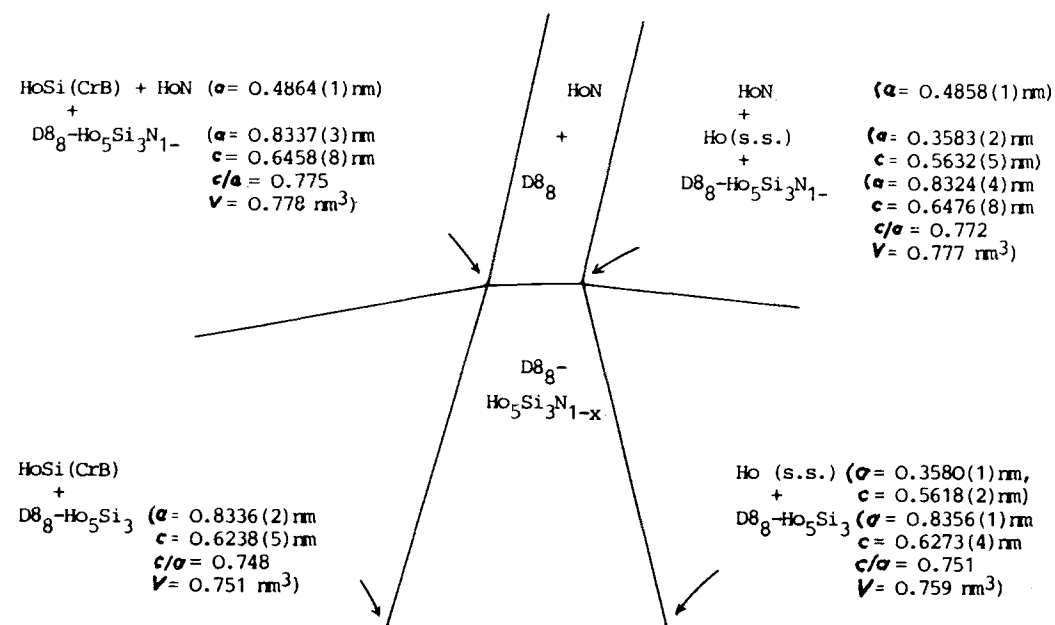


Figure 5 The phase field of the $D8_8$ -phase $Ho_5Si_3N_{1-x}$ (schematic drawing).

Ho_5Si_3 . The eutectic between Ho_5Si_4 and the congruent melting phase Ho_5Si_3 is near 58 at % Ho. The composition of the eutectic between Ho_5Si_3 and holmium could not be uniquely identified by the metallographic data of the present work.

No ternary phase is observed in the system Ho-Si-N at 1000 °C. Si_3N_4 reacts with up to 45 at % holmium to form $HoSi_{2-x}$ and HoN, the only holmium nitride existing in the binary Ho-N [24]. HoN coexists, in addition to $HoSi_{2-x}$, with HoSi and

$Ho_5Si_3N_{1-x}$, which is formed by solid solution of nitrogen in binary Ho_5Si_3 as evinced by the increase of the lattice parameters (Fig. 5). HoSi in coexistence with $HoSi_{2-x}$ and HoN has FeB-type structure; HoSi coexisting with HoN and $Ho_5Si_3N_{1-x}$ crystallizes in the CrB-type structure. This supports the opinion, that the allotropy of HoSi is composition dependent. Lattice-parameter variations of Ho coexisting with $Ho_5Si_3N_{1-x}$ and HoN indicate a considerable solubility for nitrogen in holmium (Fig. 6).

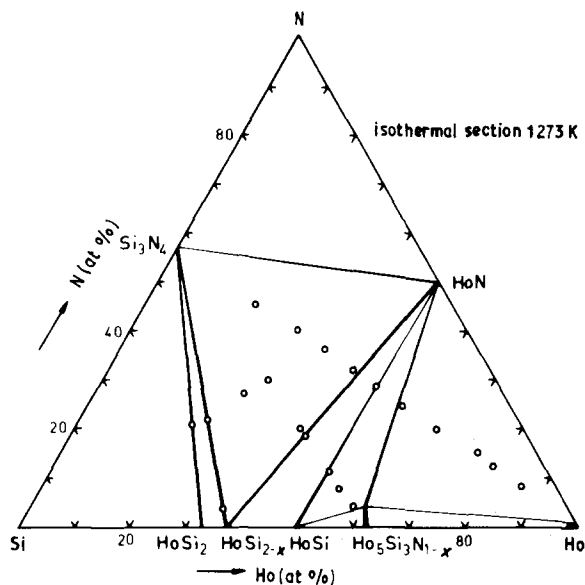


Figure 6 Isothermal section of the Ho-Si-N system at 1000 °C.

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